Large enhancement in photon detection sensitivity via Schottky-gated CdS nanowire nanosensors

Te-Yu Wei,1,2 Chi-Te Huang,1,3 Benjamin J. Hansen,1 Yi-Feng Lin,4 Lih-Juann Chen,3 Shih-Yuan Lu,2,a) and Zhong Lin Wang1,a)
1School of Materials Science and Engineering, Georgia Institute of Technology, Atlanta, Georgia 30332, USA
2Department of Chemical Engineering, National Tsing-Hua University, Hsinchu 30013, Taiwan
3Department of Materials Science and Engineering, National Tsing-Hua University, Hsinchu 30013, Taiwan
4Department of Chemical Engineering and R&D Center for Membrane Technology, Chung Yuan Christian University, Chung Li 320, Taiwan

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The Schottky contact based photon detection was demonstrated using CdS (visible light responsive), silicon (indirect n-type oxygen-non-adsorbing), and CuO (indirect p-type oxygen-adsorbing) nanowire nanosensors. With changing one of the two nanowire-electrode contacts from ohmic to Schottky, detection sensitivities as high as $10^5$% were achieved by the CdS nanowire nanosensor operated at the reverse bias mode of $-8$ V, which was 58 times higher than that of the corresponding ohmic contact device. The reset time was also significantly reduced. In addition, originally light nonresponsive silicon and CuO nanowires became light responsive when fabricated as a Schottky contact device. These improvements in photon detection can be attributed to the Schottky gating effect realized in the present nanosensor system by introducing a Schottky contact. © 2010 American Institute of Physics. [doi:10.1063/1.3285178]

Photon detection, in ultraviolet (UV) or visible light regime, finds a wide range of applications in environment, space research, and optical communication. Nanowires (NWs) are the functioning element in nanosized photon detection sensors owing to their large surface-to-volume ratios and demonstrated high sensitivities. For photon detection applications, fast response time, fast reset time, and high sensitivity are desired. In traditional design of NW nanosensors, maintaining a good ohmic contact state at the two contact ends of the NW is critical for the device performance. The purpose is to minimize the contact resistance and emphasize the effect from the changes in the surface state of the NW. To create a good ohmic contact with NWs of semiconductors like ZnO, SnO, etc., one often dopes Ga into the Pt electrode. For such ohmic contact based devices (OCD), the main mechanism of detection is based on the changes of the intrinsic conductance of the whole NW. Recently, our group demonstrated a design of NW nanosensors in which one end of the NW is purposely made Schottky contact. Such Schottky contact based devices (SCD) exhibited unusually high sensitivities and short response and reset times, attributable to the gating effect of the Schottky barrier modulated by the local adsorption of the analyzed species at the contact, which have shown gigantic enhancements in sensitivity as well as response and reset times in strain sensor, UV, bio, and gas nanosensors.

In this letter, the concept of SCD is extended to other types of semiconductor NWs, including visible light responsive CdS, indirect p-type oxygen-adsorbing CuO, and indirect n-type oxygen nonadsorbing silicon NWs. Larger enhancements were achieved with white light illumination for CdS NWs, and originally light nonresponsive CuO and silicon NWs turned light responsive. These phenomena can all be related to the gating effect of the Schottky contact.

The CdS NWs were synthesized by a PVD process, the silicon NWs by a vapor transport and condensation method, and the CuO NWs by oxidation of copper substrates. The fabricated photon detectors were characterized by using light sources of white light (equipped in an optical microscope), green light (laser pointer), and ultraviolet (UV) lamp (Spectroline, Model ENF-280C, 254 and 365 nm). The I-V curves were recorded with a semiconductor characterization system (Keithley Instruments 4200).

The inset of Fig. 1(a) shows the optical microscopy (OM) image of the CdS NW based OCD. The dark potion is the gap between the two Pt electrodes, and the two small

![Image](https://via.placeholder.com/150)

FIG. 1. (Color online) (a) I-V characteristics of CdS NW based OCD under four different light illumination conditions. The inset shows the OM image of the OCD. (b) The response curves of the OCD under illumination of three different light sources. (c) I-V characteristics of CdS NW based SCD under four different light illumination conditions. The inset shows the OM image of the SCD. (d) The response curves of the SCD under illumination of three different light sources.

Authors to whom correspondence should be addressed. Electronic addresses sylu@mx.nthu.edu.tw and zlwang@gatech.edu.
The reproducibility of the response pattern is excellent. The sensitivity, under white light, UV 254 nm, and 365 nm illumination gave the largest enhancement ratio. Figures 2(b) shows a typical comparison for the reset times of the OCD and SCD under white light illumination. The reset time is defined as the time needed to achieve a 37% deviation from the initial state, from which one can judge the rate of the reset process. Evidently, the reset time of the SCD (320 ms) was significantly shorter than that of the OCD (572 ms) under white light illumination. As for the UV illumination cases, the same trend persists, with 57 versus 343 ms for the UV 254 nm case and 380 versus 640 ms for the UV 365 nm case (data not shown here).

When operated at the reverse bias mode, the electron would flow from the Pt electrode to the CdS NW, overcoming or tunneling through the Schottky barrier, provided a large enough bias voltage is applied. In addition, the oxygen of the air atmosphere adsorbed not only on the surface of the CdS NW but also at the Schottky contact. When the device was illuminated with light of sufficient energy, there were electron-hole pairs generated via the optical absorption and the photon-generated electron-hole pairs were separated by the strong local electrical field existing at the Pt-NW interface. Part of the adsorbed, negatively charged oxygen ions combined with the holes generated from the optical absorption and subsequently desorbed, reducing the electron depletion layer thickness. The current values were near zero when the light was off and jumped to a steady higher value once the light was on. The current dropped off when the light was turned off but in a much slower rate exhibiting an apparent tailing. Evidently, the response was much faster than the reset in the present OCDs, consistent with the phenomenon observed for the ZnO NW based OCD. The current response curves recorded under the three different light sources with the device operated at the reverse bias mode of −8 V were shown in Fig. 1(d). The large enhancements in current pick-up upon light illumination for the SCD over the corresponding OCD are evident from the comparison of Figs. 1(b) and 1(d) in the scale of the vertical axis. Also evident to note is the sharp drop of the current at reset, implying much shortened reset times. The sensitivities under white light, UV 254 nm, and 365 nm illumination at the reverse bias mode of −8 V were determined to be 101, 975, 9448, and 18 296%, which were 58, 10, and 17 times higher than those of the corresponding OCDs, respectively. These data were presented in Figs. 2(a). Note that the white light illumination gave the largest enhancement ratio.

To further explore the potential merits of the SCD, we also investigated the SCDs constructed using silicon and CuO NWs as the functioning element. Both silicon and CuO NWs are indirect band gap semiconductors, with silicon being n-type and non-oxygen-adsorbing whereas CuO p-type and

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**FIG. 2.** (Color online) (a) Sensitivity vs illumination light source for CdS NW based OCD and SCD. (b) The reset process of CdS NW based OCD and SCD.
oxygen-adsorbing. It is interesting to study how materials characteristics affect the performance of SCD. Figures 3(a) and 3(b) show the I-V curves for the silicon NW based OCD and SCD, respectively, under dark and white light illumination conditions. For the OCD case, both I-V curves exhibited a good ohmic contact behavior and there were no appreciable changes in currents, indicating the idleness of the silicon NW based nanosensors toward light exposure. As to the SCD case, both I-V curves showed Schottky contact characteristics, and slight current changes were obtained at some bias voltage regions upon white light illumination. When the bias voltage was set at −8 V, the current pick-up was about 2 nA, corresponding to a sensitivity of 8%. Note here that silicon is non-oxygen-adsorbing, and thus lacks the electron flow modulation ability both in electron flow channel width and Schottky barrier characteristics (SBH and SBW), through oxygen adsorption-desorption. Consequently, the silicon NW based OCD appeared practically light nonresponsive. The slight sensitivity of the SCD came from the increasing charge carrier density resulted from the strong local electrical field existing at the NW-Pt interface. The originally light nonresponsive CuO based NW nanosensor turned slightly light responsive because of the introduction of the Schottky contact.

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FIG. 3. (Color online) (a) The I-V characteristics of silicon NW based OCD under dark and white light illumination. (b) The I-V characteristics of silicon NW based SCD under dark and white light illumination. (c) The I-V characteristics of CuO NW based OCD under three different illumination conditions. (d) The I-V characteristics of CuO NW based SCD under three different illumination conditions.